



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant

Seiichiro KANNO et al.

Serial No.

10/679,342

Filed

7 October 2003

For

SEMICONDUCTOR MANUFACTURING APPARATUS AND METHOD OF PROCESSING SEMICONDUCTOR WAFER USING PLASMA AND WAFER VOLTAGE PROBE

Art Unit

Unassigned (Parent - 1763)

Examiner

Unassigned (Parent - Ram N. Kackar)

Conf. No.

Unassigned (Parent - 4591)

SUPPLEMENTAL PRELIMINARY AMENDMENT

Commissioner for Patents POB 1450 Alexandria, Virginia 22313-1450

10 December 2003

Sir:

Supplemental to <u>and after entry of</u> the Preliminary Amendment filed 7 October 2003, <u>and prior to examination on the merits in the above-identified application</u>, the following amendments and remarks are respectfully submitted.

In accordance with the revised format of the manner of making amendments under 37 CFR §1.121 as set forth in the Final Rule effective 30 July 2003, each section of amendment herein begins on a new page, and changes are shown by strike-through (or double brackets where appropriate) and underlining to indicate deletions and additions, respectively. A complete listing of all claims ever presented in the application is given with the current status of each claim, and only the text of all pending and withdrawn claims is presented in full, with those not being amended herein being presented in clean version.